## DXB-S7BG

## 7B (G) / 7A (G) / W Serial

- · The Equipment is a Double-work bench.
- Measurement of the angle in the direction of the end face or reference edge of the wafer/ingot.
- Manually operated measurements, manual judgement of peaks.
- Variety of other sample stages are available, suitable for special size crystals, and special measurement requirements.



## 7BN (G) / 7AN (G) Serial

- · The Equipment is a Double-work bench.
- Measurement of the angle of the end face or NOTCH crystal direction of the ingots/wafer.
- Manually operated measurements, manual judgement of peaks.





ltem	Specifications
Crystal Diameter	125~200mm, ±1mm
Crystal length	Crystal length within 300mm, Wafer Thickness 0.5mm~2.0mm
Measurement angle	0~50°
Accuracy	±30" or ±15"

[Extended Functions]:
Difference value display,
Data load,
Data upload;,
Semi-automatic detection,
Crystal detection of
declination, etc.

## Protection







